

[54] PROTECTIVE FACE MASK

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[\*\*] Term: **14 Years**

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[51] Int. Cl. .... **D28—03**

[52] U.S. Cl. .... **D29/8**

[58] Field of Search ..... **D86/10 A; D88/2; D2/234; 132/9, 45 R, 88.5; 2/9, 11, 173-174, 206**

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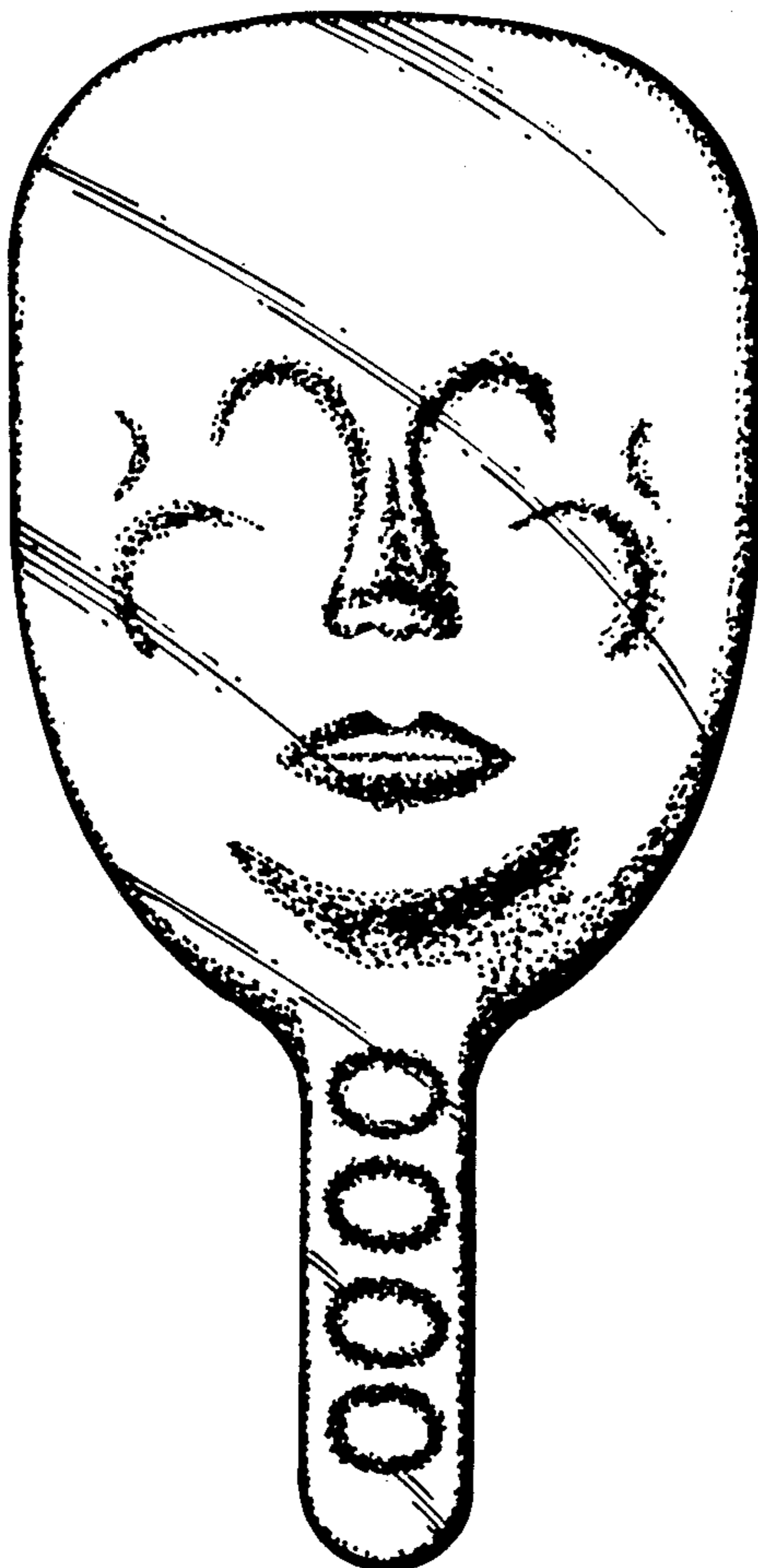
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[57] **CLAIM**

The ornamental design for a protective face mask, as shown.

**DESCRIPTION**

FIG. 1 is a front elevational view of a protective face mask showing my new design;  
FIG. 2 is a right side elevational view thereof;  
FIG. 3 is a top plan view thereof;  
FIG. 4 is a bottom plan view thereof; and  
FIG. 5 is a rear elevational view thereof.



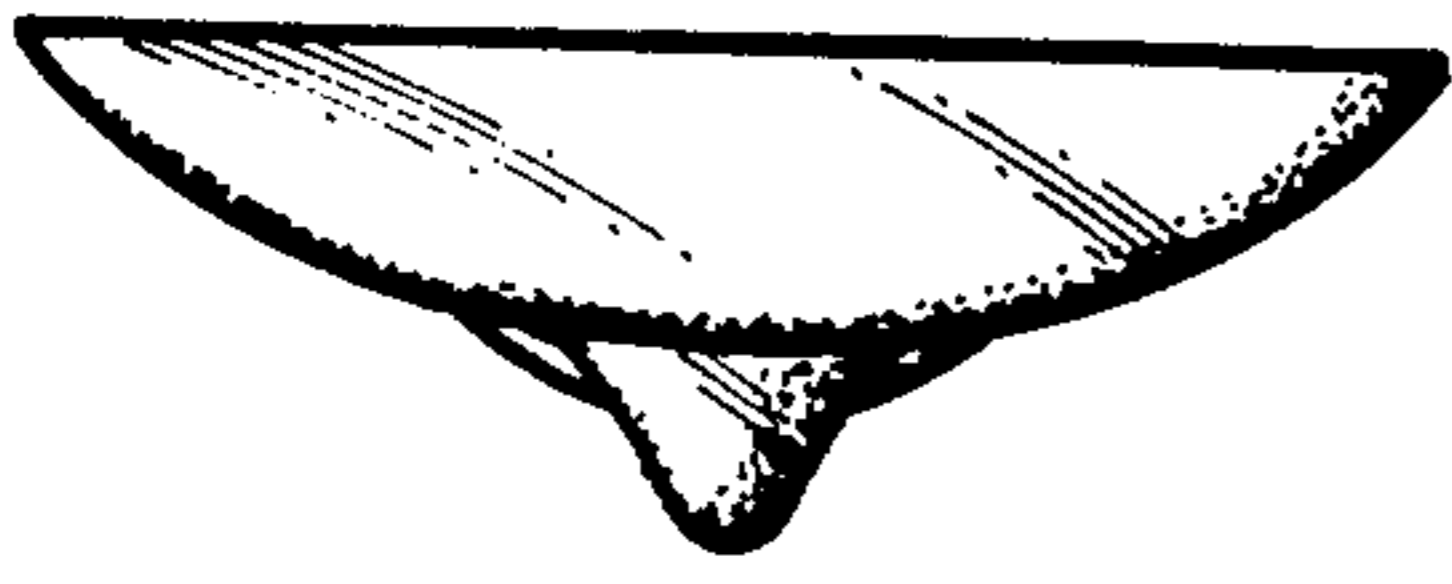


FIG \_ 3

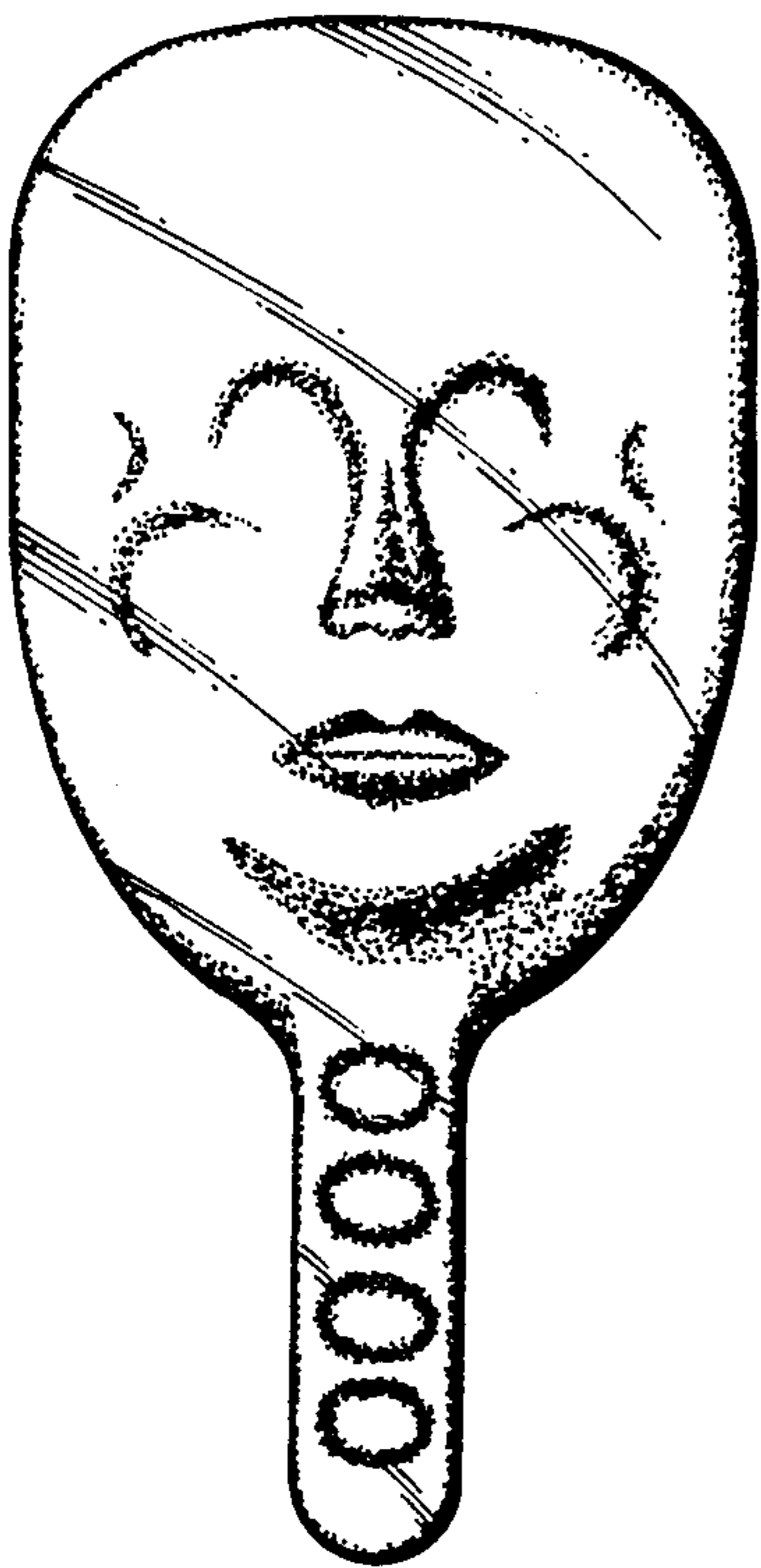


FIG \_ 1



FIG \_ 2

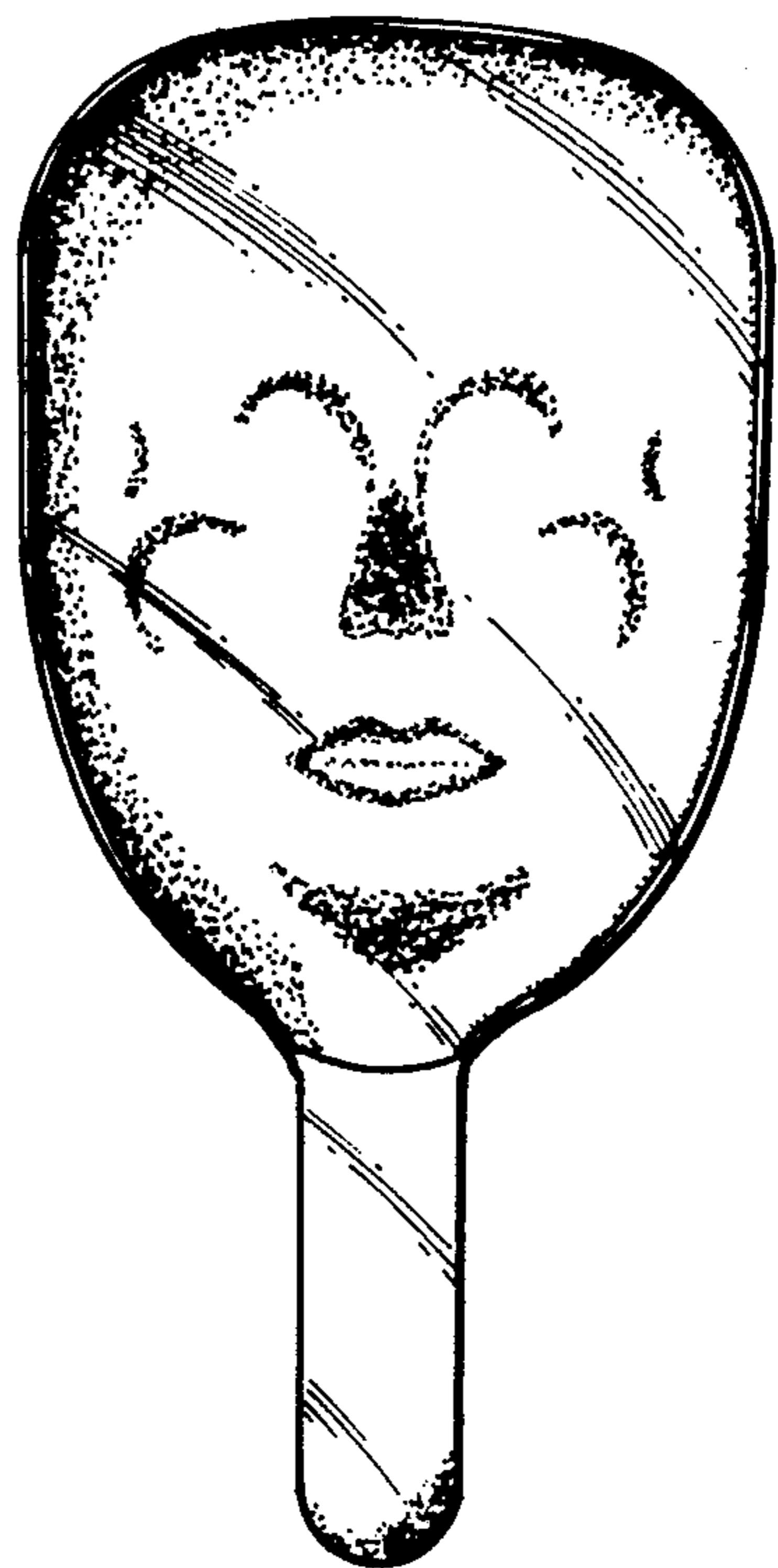


FIG \_ 5



FIG \_ 4